

	Type	L #	Hits	Search Text	DBs	Time Stamp	C o m m e n t s	E r r o r m e s s a g e s	E n d o f r o n t
1	BRS	L8	204	(sac or "contact hole") same ("hard mask" or SiO2 or SiN or Si3N4 or "silicon dioxide" or "silicon oxynitride" or SiON or SixOyNz or SiOxNy) same (BPSG)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/10/03 10:38			0
2	BRS	L15	75	8 and @pd<=19980927	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/10/03 10:40			0